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ABSTRACT OF THE DISCLOSURE

The invention relates to an apparatus for applying at least one coating to objects by means of physical vapour deposition (PVD) under vacuum, including: a preprocessing device for performing a preprocessing on the object; a PVD device for coating an object under a vacuum; and a postprocessing device for postprocessing the objects, wherein: the apparatus comprises a transport device which extends through the preprocessing device, the PVD device and the postprocessing device, the transport device is adapted to transport objects arranged on carriers, and the PVD device is adapted for semi-continuous treatment of objects arranged on the carriers.

09331599-082701
FOI/280-6657860